

# Electrical-field bidirectional switching of full MTJs

A full MTJ stack device with bidirectional magnetization switching purely through an electric field

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## Applications

• Spin based memory and logic devices

## **Key Benefits & Differentiators**

- Electrical-field switching of MTJs: consumes low power while improving speed and reducing error rate
- Ultralow energy performance: Current does not pass through a high resistive tunnel barrier
- **Easy integration to currently available devices:** Compatible with current standard CMOS technology and with geometry structure similar to currently available devices

## **Electrical-field bidirectional switching of MTJs**

The scaling of conventional semiconductor devices are highly dependent on device reliability and power consumption. Improvements in these two critical factors are continuously pursued. Currently, electrical field switching of perpendicular magnetic tunnel junctions (p-MTJs) either uses an external magnetic field or spin transfer torques to break the time-reversal symmetry for switching. However, MTJ devices with switching relying only on the electrical field can achieve lower power consumption and error rates.

Researchers at the University of Minnesota have developed a bidirectional switching mechanism of a full MTJ stack and device that, unlike other technologies, relies only on the electrical field. This proposed technology performs bidirectional switching of the perpendicular magnetization via the electric-field manipulated exchange coupling of the synthetic antiferromagnetic free layer. This E-field driven magnetization switching of MTJ devices approach enables ultralow energy performance, ultrafast switching speed, low write error rate and read disturbances. This technology is compatible with currently used geometry and standard CMOS technologies, which facilitates easy integration with conventional devices in the market. This invention can also be used as a novel design for spin based memory and logic devices. The proposed device has high stability, scalability, and can easily be fabricated in wafer scale.

## **Phase of Development**

## TRL: 7

This technology has been tested in a relevant environment and is under experimental validation. The bidirectional magnetization switching has been demonstrated in p-MTJs with the synthetic antiferromagnetic free layer. The exchange coupling change by electric-field was observed through gating and tunneling effect

# Technology ID 2019-361

## Category

Engineering & Physical Sciences/Design Specifications Engineering & Physical Sciences/Instrumentation, Sensors & Controls Engineering & Physical Sciences/Nanotechnology Engineering & Physical Sciences/Semiconductor Software & IT/Algorithms

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## Researchers

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## References

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